

DC Characterization Data Kurt Lesker PVD 75

Metal	Film Thickness	Base pressure	Capman Pressure	Power	Sputtering Time	Target Size
Titanium (Ti)	79 nm	5x10 ⁻⁶ Torr	5 mTorr	300 W	10 min	4 inches
Nickel (Ni)	159 nm					
Chromium (Cr)	147 nm		5 mTorr	500 W	5 min	4 inches
Aluminum (Al)	100 nm					
Platinum (Pt)	100 nm					